SANKYO KASEI KK 2002-541092/58 C23C 18/28, 18/31, H05K 3/38, 3/00 2000.09.18 2000-281398(+2000JP-281398) (2002.03.29) H05K 3/18,

catalyst to roughened material surface, and forming conductive layer on catalyst surface interface, involves forming resin mask on base material, providing Manufacture of molded circuit component used as connector for C2002-153572

NOVELTY

conductive layer (4) of preset pattern is formed on catalyst surface (3). resin mask (2) of polyamide group polymer is provided on base by synthetic resin. Surface (1a) portion of base material, is exposed. A material and roughened. A catalyst is provided to roughened surface (1b). Subsequently, mask is removed from base material, and a The dielectric base material (1) of predetermined form is formed

DETAILED DESCRIPTION

by synthetic resin material. The surface (1a) portion of the base material on which conductive layer (4) of predetermined form to be formed, is exposed. Subsequently, a resin mask (2) of polyamide The dielectric base material (1) of predetermined form is formed

A(5-F1E2, 11-C4D, 12-E7) L(3-H3, 3-H4E1)

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provided to the roughened surface (1b), by non-electrolytic plating. exposed portion of the base material is covered. The surface of the predetermined pattern is formed on the surface (3) on which the formic acid, benzyl alcohol or metacresol, and the conductive layer of Subsequently, the resin mask is removed from the base material by base material exposed from the resin mask is roughened. A catalyst is group polymer for covering base material, is provided such that the catalyst is provided

USE

dimensional circuit substrates, especially built-in antennae of mobile telephone and connector for interface. For manufacture of molded circuit component such three

surface of the coating material is made hydrophobic, and hence stain product. Since the resin mask is formed before roughening, the material, the conductive layer is formed as design and as a reliable Since the resin is formed from the polyamide group polymeric JP 2002094218-A+

of product and adherence of water content are prevented

Surfaces 1a,3 Dielectric base material 1 of molded circuit component. DESCRIPTION OF DRAWING

The figure shows the sectional drawing of manufacturing process

TECHNOLOGY FOCUS

Resin mask 2

Conductive layer 4

Roughened surface 1b

crystal polymer (LCP) chosen from polyester group resin, polybutylene terephthalate (PBT) and polyethylene terephthalate (PBT). The base material surface is roughened using caustic potash or caustic soda. Polymers - Preferred Polymer: The dielectric base material is liquid

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